

# Small Signal Diode Models

- This small signal diode model is for the mid-band frequency range
- At high frequencies, impedances due to parasitic C's become a factor
- SPICE will model these parasitics if the values are properly entered in the device models

\*\*\*\*\*

\* B2 Spice default format (same as Berkeley Spice 3F format)

```
diode 1 0 40eps12
```

```
R 2 1 1K
```

```
V 2 0 DC 0
```

```
IVm 1 0 0
```

```
.model 40eps12 D is = 1e-15 rs = 0.00426912 n = 0.926332 tt = 1e-09 cjo = 1e-11 vj = 0.7  
+ m = 0.5 eg = 0.6 xti = 0.5 kf = 0 af = 1  
+ fc = 0.5 bv = 1200 ibv = 0.0001
```

# Junction (Depletion) Capacitance

- Depletion capacitance in terms of SPICE3 model parameters

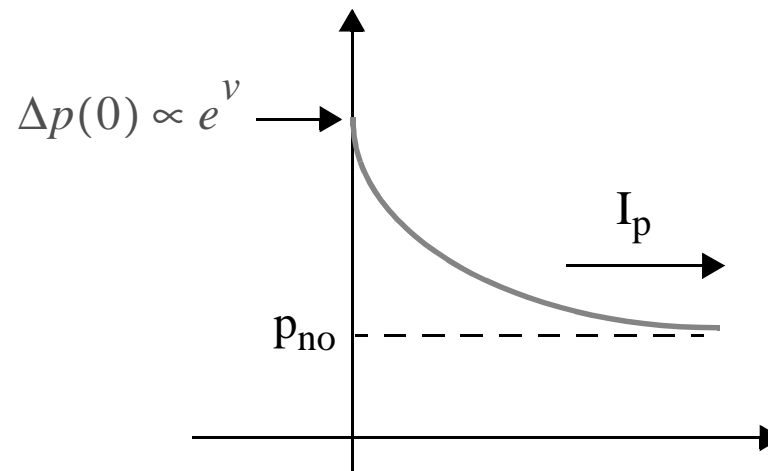
$$C_j = \frac{C_{j0}}{\left(1 - \frac{V_D}{V_j}\right)^m}$$

- This is the dominant capacitance component under reverse bias conditions
- It is also present under forward bias conditions --- since there is a depletion region
- For forward bias, this equation is not very accurate, and  $2C_{j0}$  is used (why is it greater than  $C_{j0}$ ?)
- But this is not the dominant component for forward bias

# Forward Bias Small Signal Diode Models

- Dominant capacitance is due to stored diffusion charge
- If n-side is more lightly doped than p-side, then diffusion current is dominated by holes injected into the n-side

$$\frac{Q_p}{\tau_p} = I_p$$



- SPICE models this in terms of an average transit time, the average time a hole stays in the n region of the diode (or: an electron stays in the p region)

$$Q_p = I_p \tau_T$$

## Diode Models

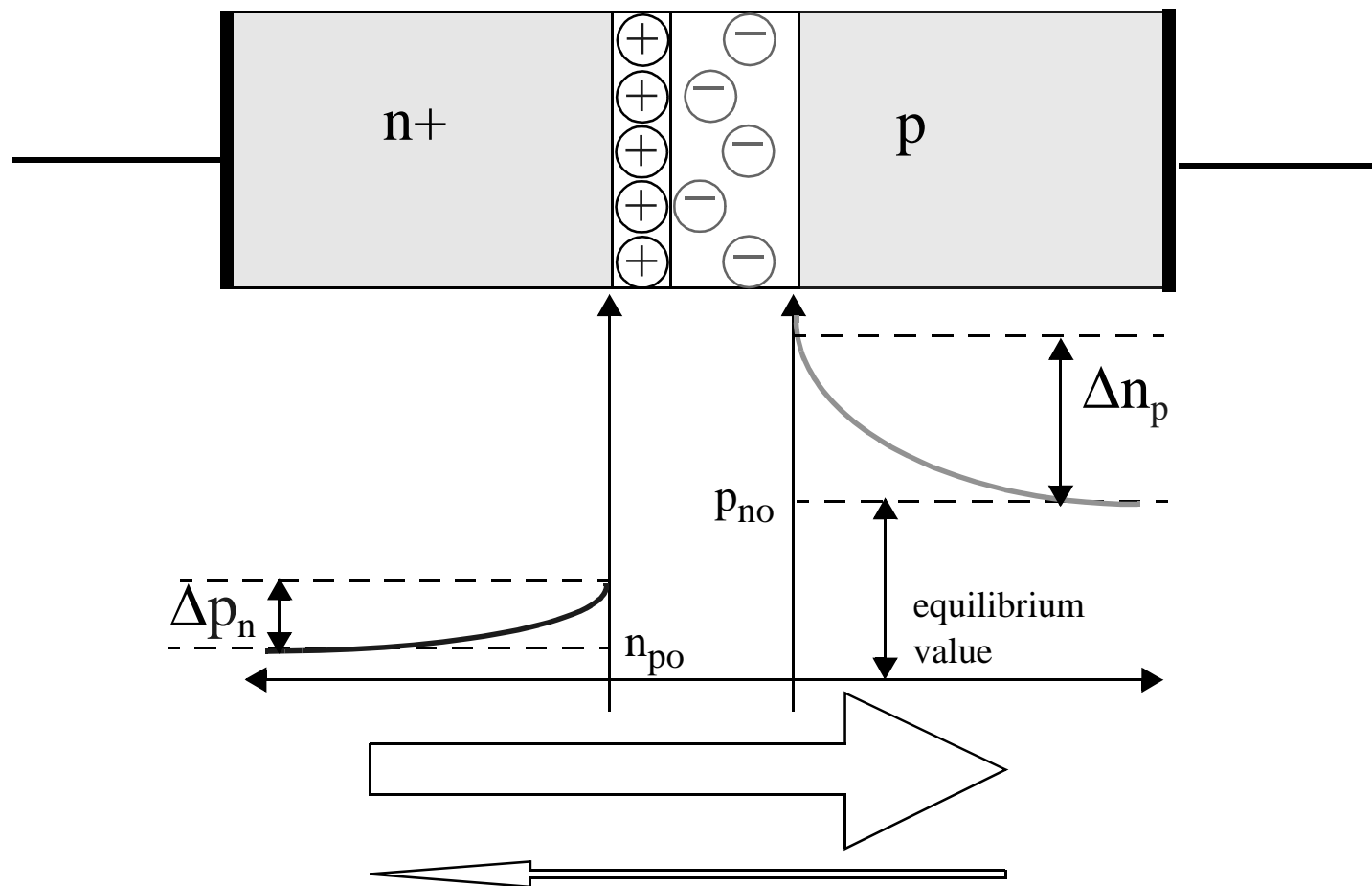
- The corresponding capacitance is nonlinear, but can be specified at an operating point
  
  
  
  
  
  
  
  
  
  
- What does the complete diode SPICE model look like?

## Small Signal SPICE Diode Models

- What does the small signal diode model look like after determining the dc operating point?

# Asymmetrical diode

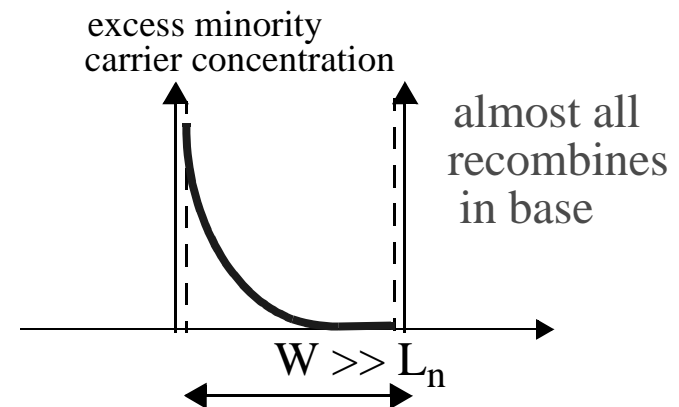
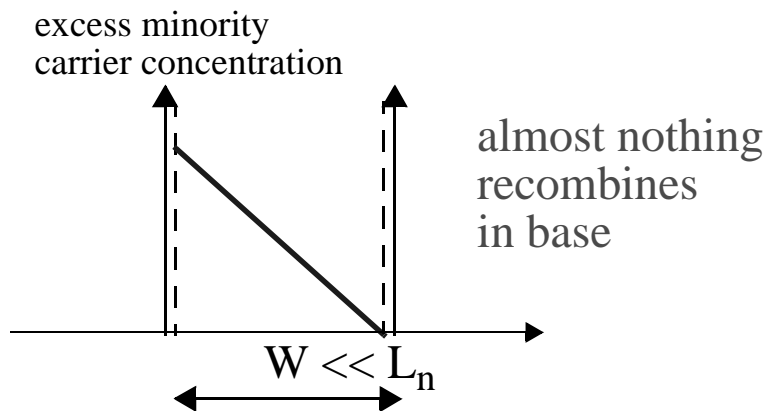
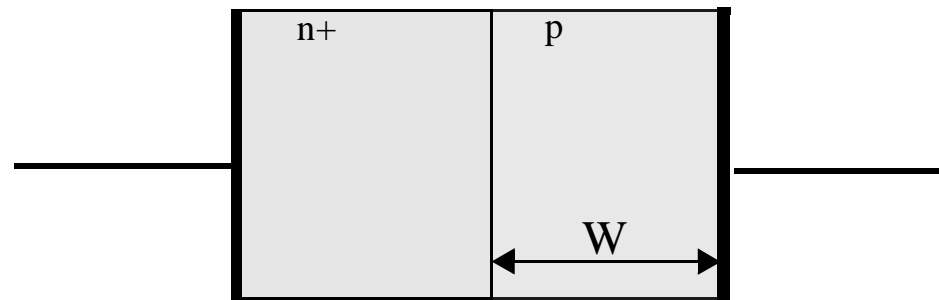
- In the asymmetrical junction ( $p^+n$  or  $n^+p$ ), the lightly doped region is sometimes called “the base”
- Usually, most of the current flowing through a  $p^+n$  or  $n^+p$  junction is due to injection of minority carriers into “base” from the highly doped region.



## Short base vs long base

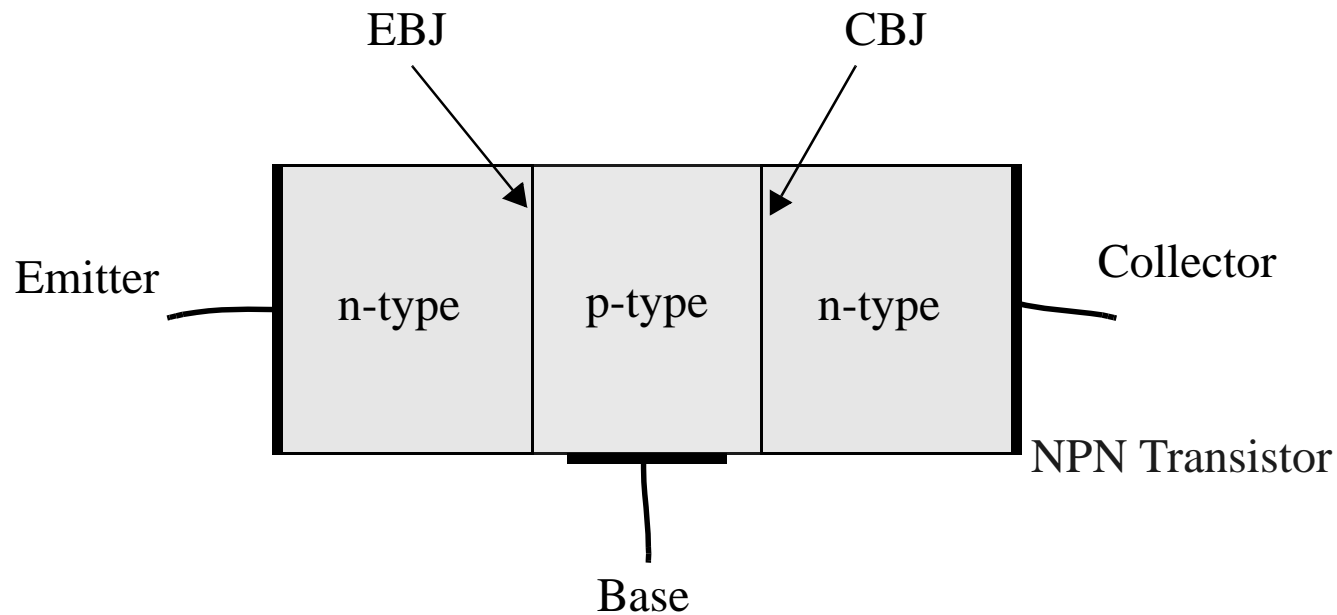
- How far, on average, a minority carrier goes in the base depends upon:
  - **Diffusion constant  $D_n$**  (how fast the particles flow)
  - **Minority carrier lifetime  $\tau_n$**  (how long a particle survives on average)
- We define a diffusion length of electrons in p type Si:

$$L_n = \sqrt{\tau_n D_n}$$



# Bipolar Junction Transistors --- BJTs

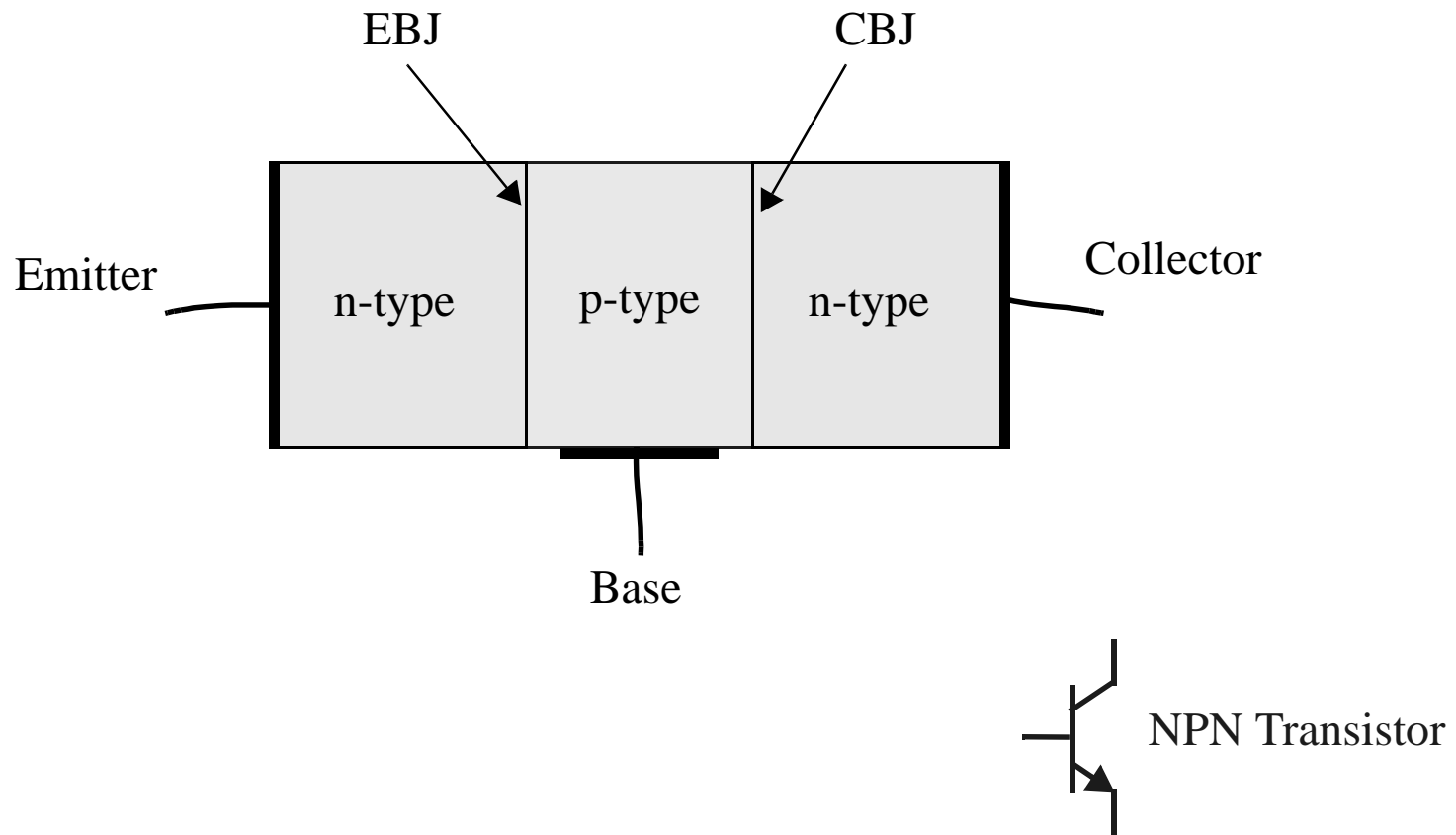
- Bipolar refers to the conduction of both holes and electrons
- Two connected p-n junctions
- But unlike diodes, provides gain/amplification -- behaves like a controlled source
- Terminology:





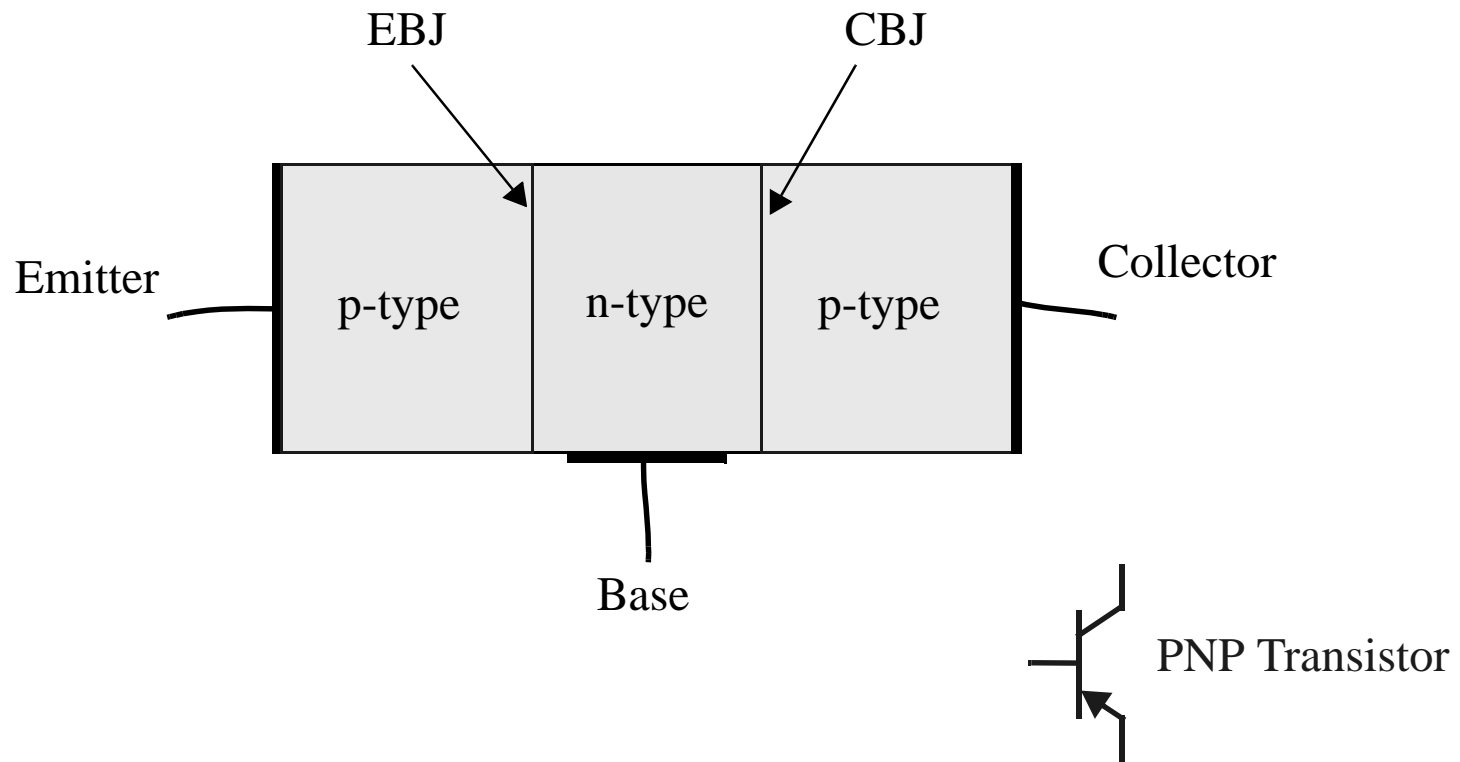
# Regions of Operation for NPN Transistor

- Cut-off: both p-n junctions are reverse biased
- Saturation: both p-n junctions are forward biased
- Active: the EBJ is forward biased and the CBJ is reverse biased



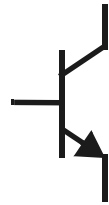
# PNP Bipolar Junction Transistor

- Regions of operation are characterized in the same way
- Cut-off: both p-n junctions are reverse biased
- Saturation: both p-n junctions are forward biased
- Active: the EBJ is forward biased and the CBJ is reverse biased



# PNP and NPN Transistors in Active Region

- Active: the EBJ is forward biased and the CBJ is reverse biased

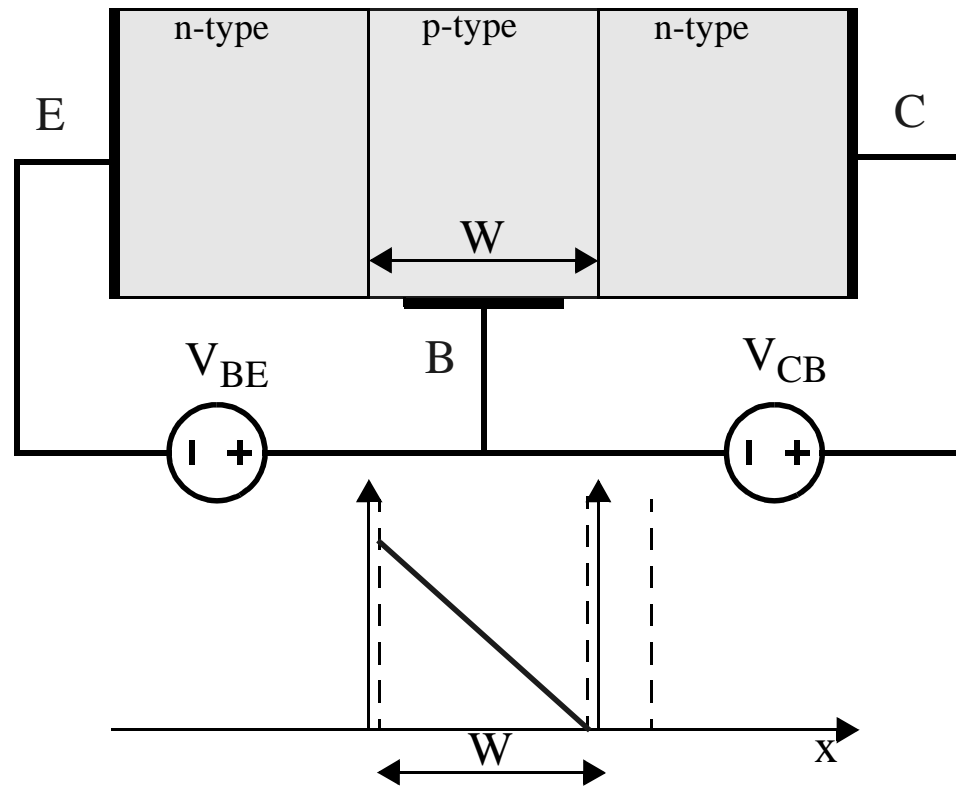


NPN Transistor



PNP Transistor

# Active Region Operation

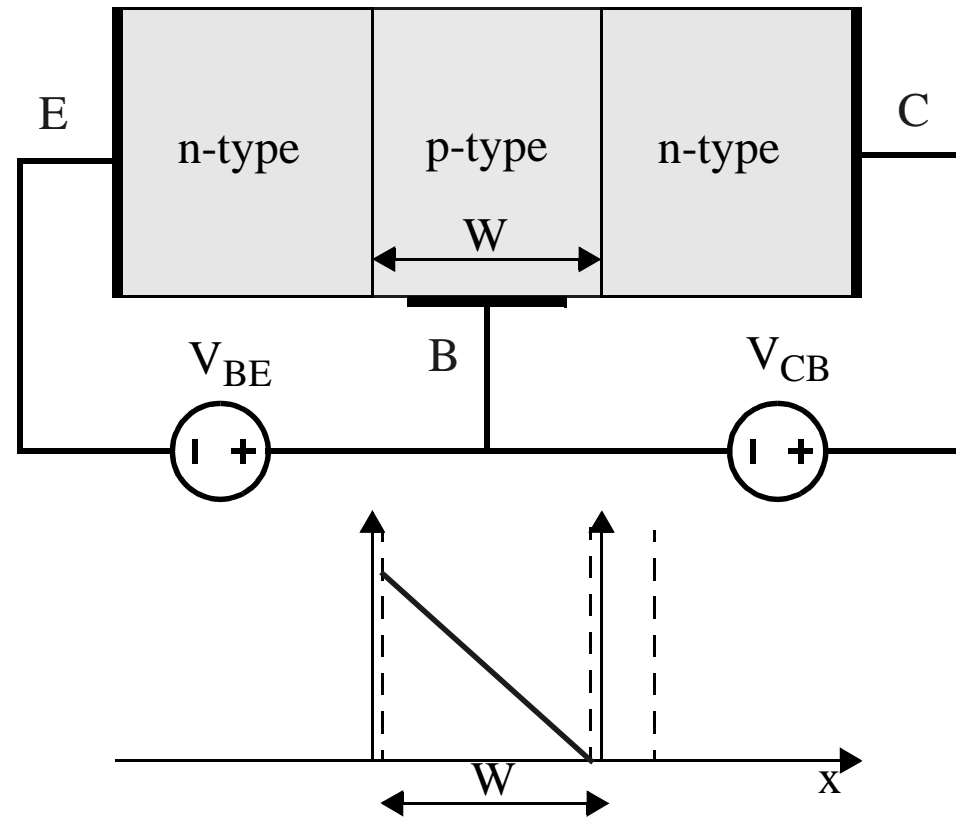


- Electrons are injected from the emitter and diffuse to the collector
- Most of the electrons will reach the collector --- depends on  $W$  and  $\tau_F$
- Excess carrier concentration at CBJ is zero since electric field collects everything

# Active Region Operation

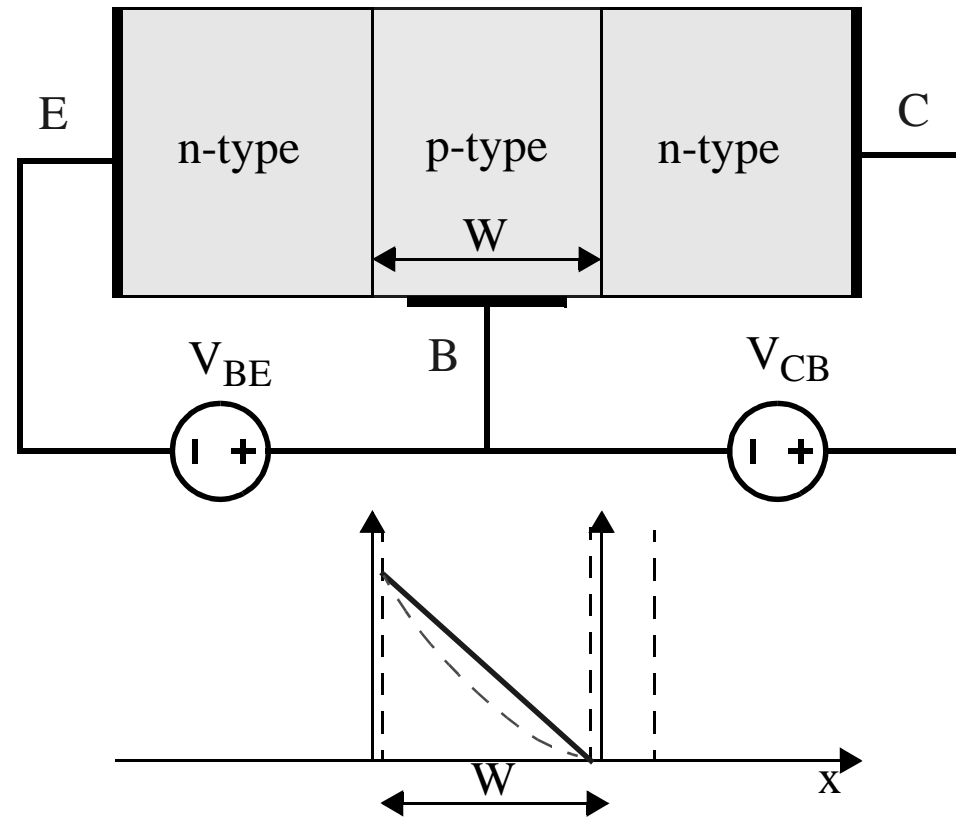
- The maximum  $n_p$  concentration at EBJ depends on the  $V_{BE}$
- The slope of the  $n_p$  distribution determines the diffusion current from collector to emitter

$$i_c \propto \frac{dn_p}{dx}$$



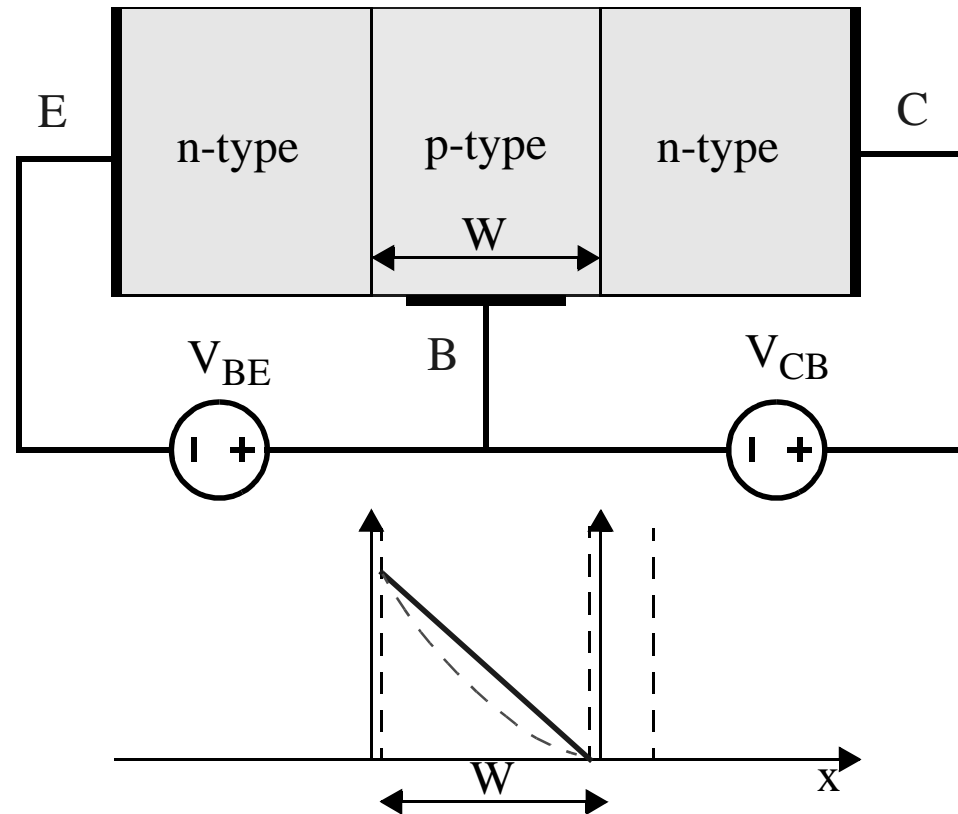
# Active Region Operation

- But some of the carriers in the base recombine
- Electrons lost to recombination correspond to holes supplied to the base --- a current  $i_b$
- The distribution is no longer linear



# Active Region Operation

- Why does the distribution change in a convex, as opposed to concave manner?



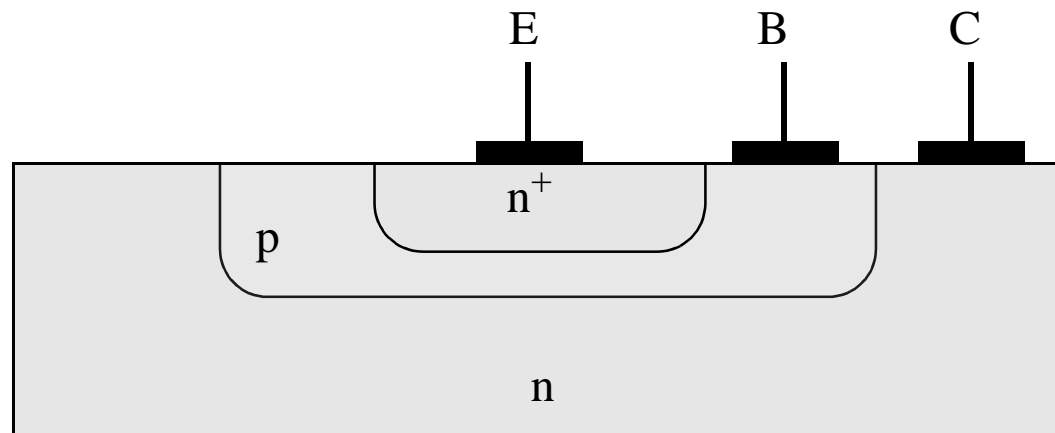
- $i_c$  is practically independent of  $V_{CB}$ . Why?

# Active Region Operation

- Assuming that there is no recombination in the base and no injection from base to emitter, the collector current,  $i_c$  is simply

$$i_c = I_s e^{v_{be}/V_T}$$

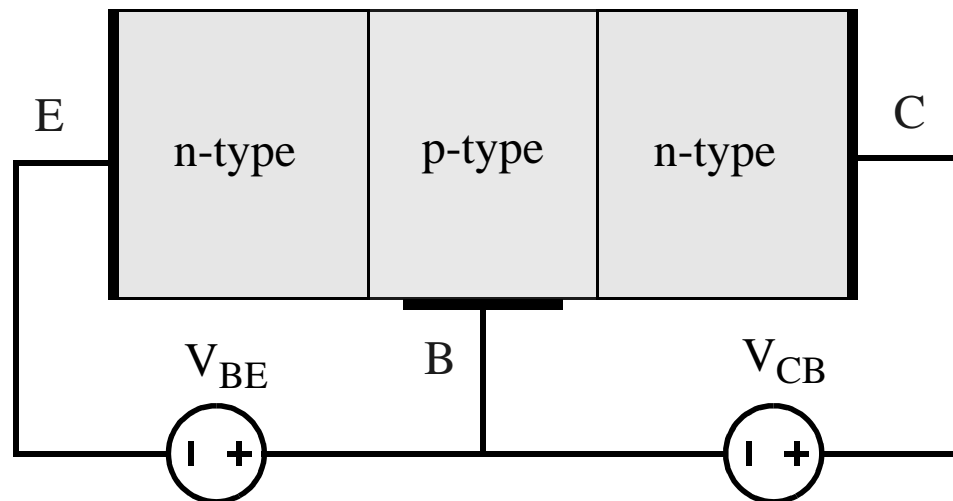
- $I_s$  is  $\sim 10^{-12}$  to  $10^{-15}$ , and directly proportional to the EBJ area
- On ICs the EBJ junctions can be used to scale one transistor size (hence current) relative to another





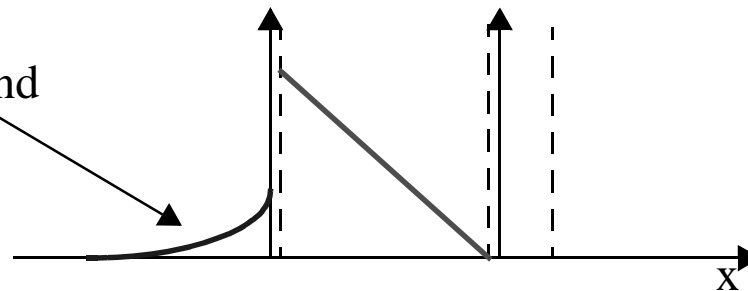
# Base Current

- $i_{b1}$ : Component due to holes from external ckt replacing those lost via recombination in the base
- $i_{b2}$ : dominant portion comes from holes injected from the base to emitter



$p_n$  is proportional to  
doping level in the base and

$$e^{v_{be}/V_T}$$



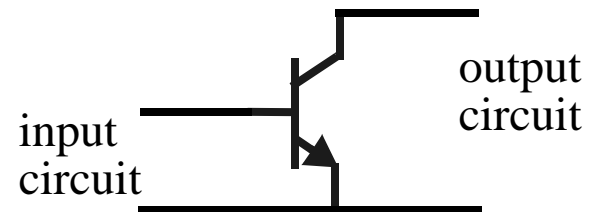
# Base Current

- Recombination current,  $i_{b1}$  is also proportional to  $e^{v_{be}/V_T}$
- Therefore, the total base current is proportional to  $i_c$

$$i_c = I_s e^{v_{be}/V_T}$$

- The proportionality factor,  $\beta$ , is the common emitter current gain:

$$i_b = \frac{i_c}{\beta} = \frac{I_s}{\beta} e^{v_{be}/V_T}$$

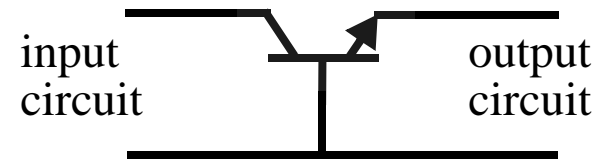


- $\beta \approx 100 - 200$ , and is determined by the BE doping levels and the width of the base,  $W$

# Emitter Current

- $\alpha < 1$  is the common base gain

$$i_c = \alpha i_e$$



- By conservation of charge:

$$i_e = i_c + i_b$$

$$i_b = \frac{i_c}{\beta}$$

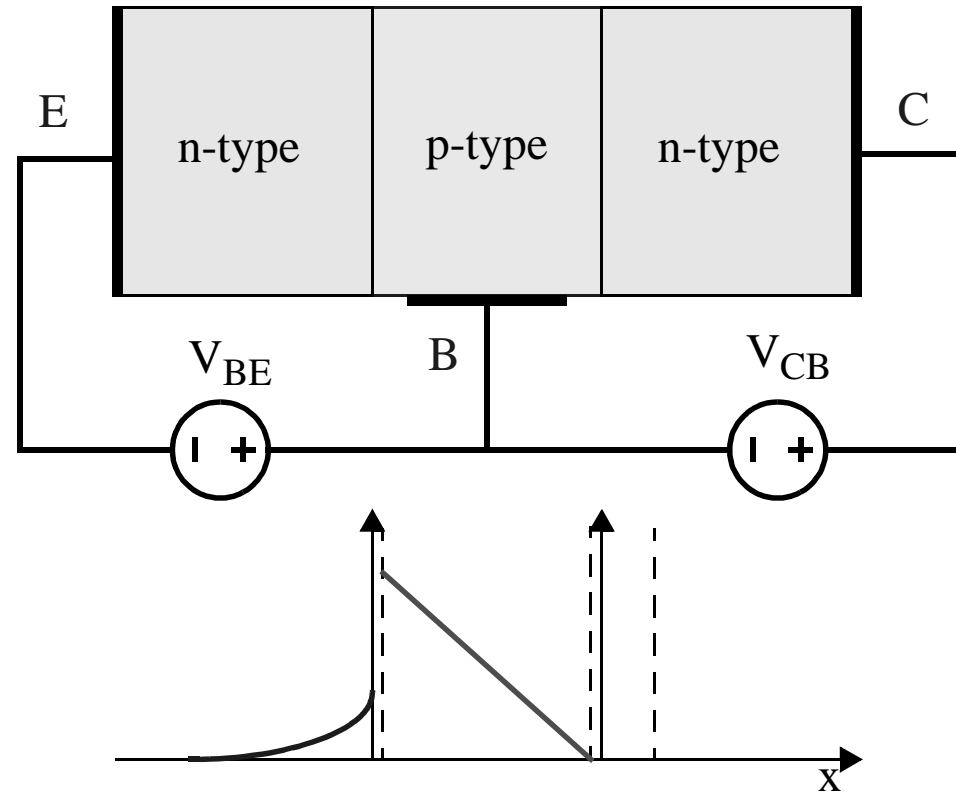
$$i_e = \frac{\beta + 1}{\beta} i_c$$

$$\alpha = \frac{\beta}{\beta + 1}$$

$$\beta = \frac{\alpha}{1 - \alpha}$$

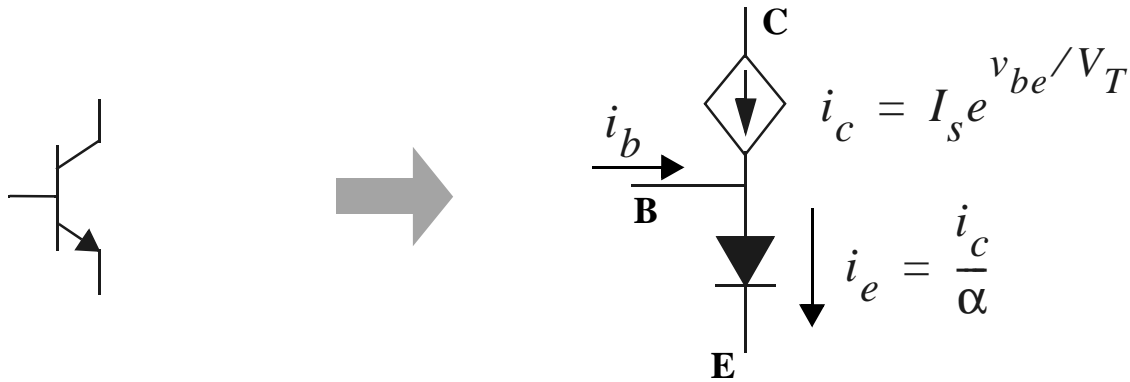
## Active Region: Controlled Source Behavior

- An applied base-emitter voltage,  $V_{BE}$ , causes a collector current that is independent of the base-collector voltage (in the active region)
- Behaves like a voltage controlled current source
- Active region is used for amplification in analog design

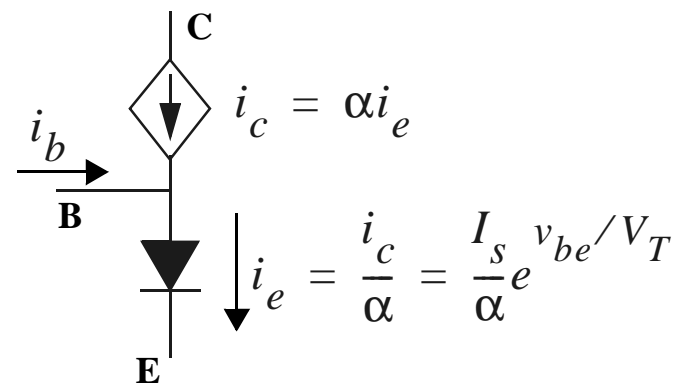


# Equivalent Circuit Models

- Please read about Eber-Moll model in Sec. 4.13 of your textbook!
- We can model the transistor behavior in the active region using diodes and controlled sources

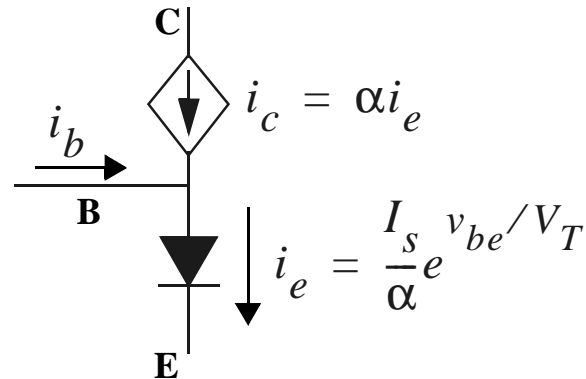


- Or, using a linear current-controlled current sources and diodes

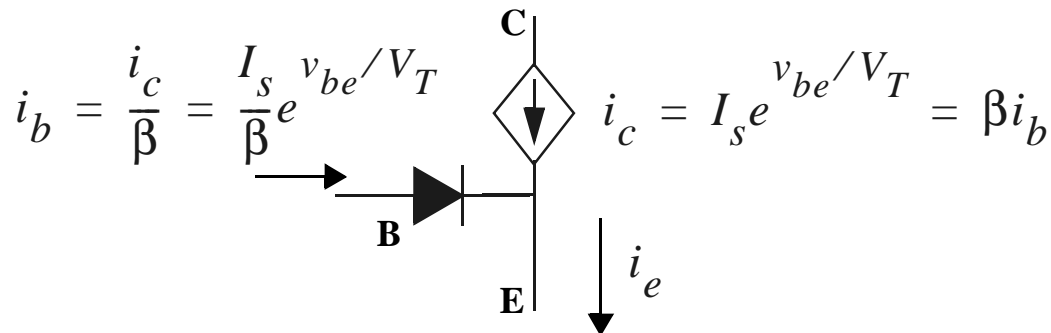


# Equivalent Circuit Models

- The circuit models on the previous page represent the transistor in terms of the common-base current gain --- gain from  $i_E$  to  $i_C$

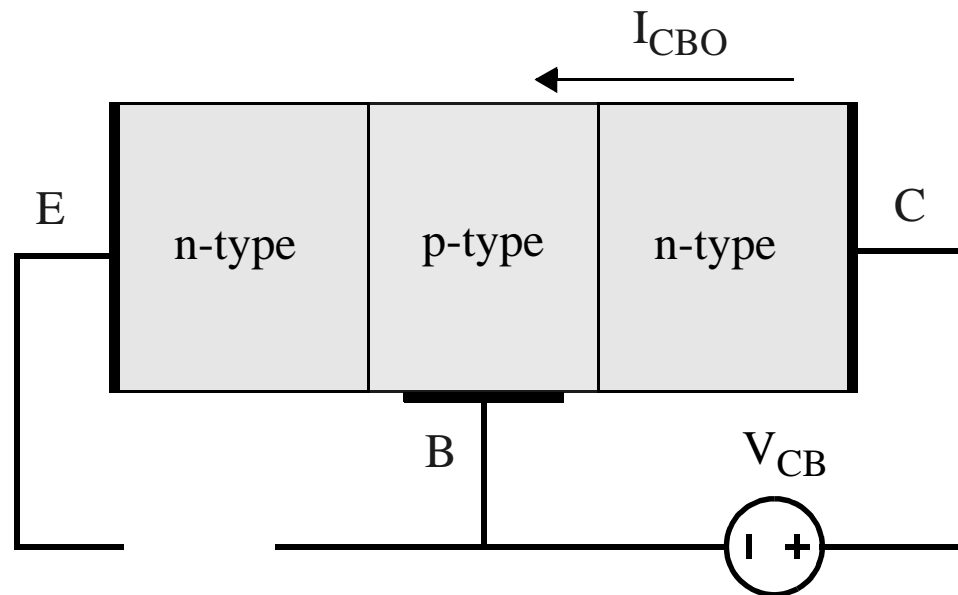


- A common emitter configuration is sometimes more useful



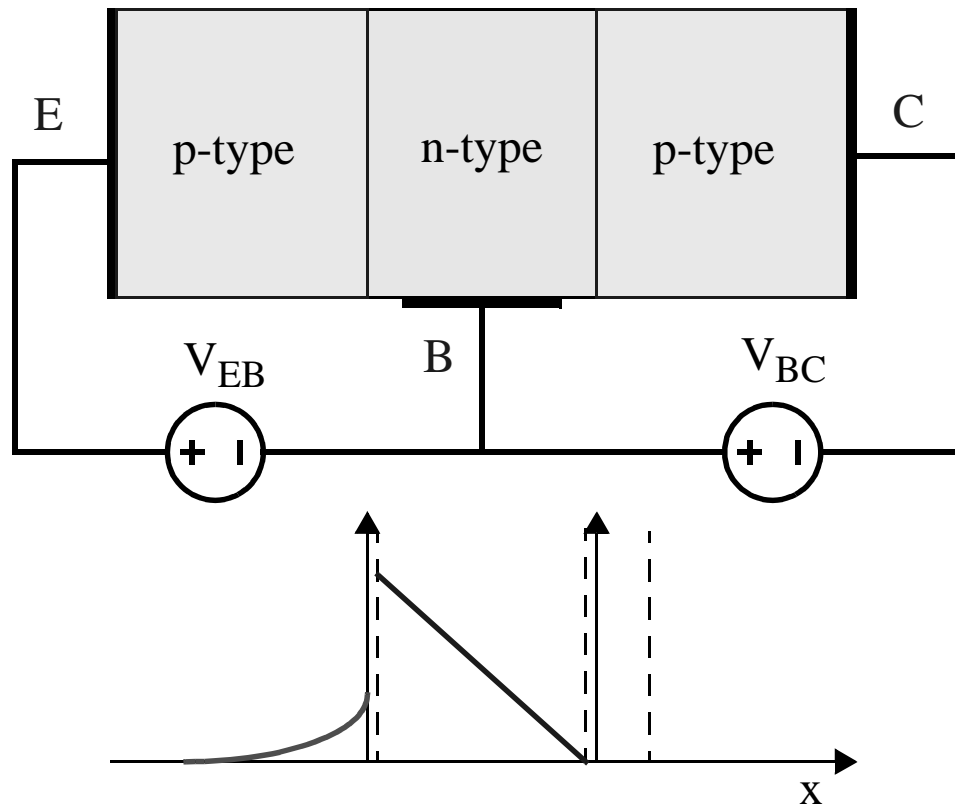
# Active Region Currents

- The only current we've ignored is a negligible one,  $I_{CBO}$ , the leakage current from the collector to the base
- $I_{CBO}$  is measured like a reverse-biased diode current with the emitter open circuited
- Like the saturation current of a diode,  $I_{CBO}$  is small and temperature dependent



## PNP: Active Region

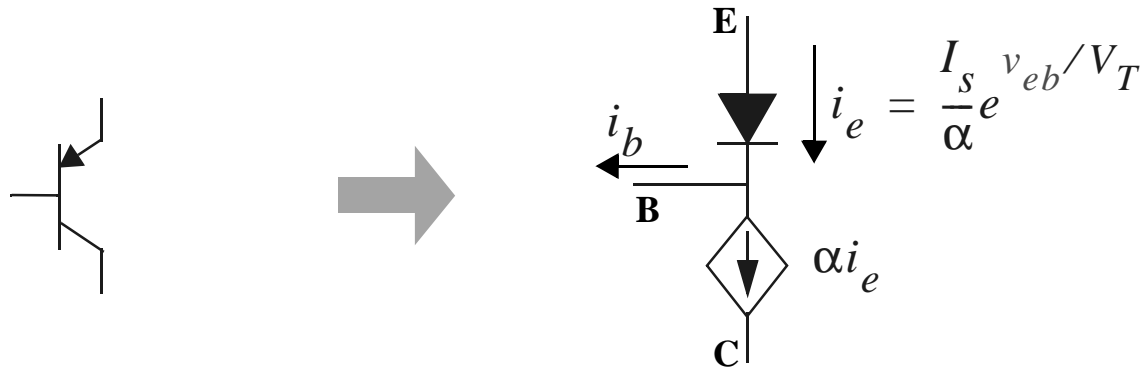
- Operates the same way as the NPN, but the applied voltages are reversed for the active region --- EBJ is forward biased and CBJ is reverse biased



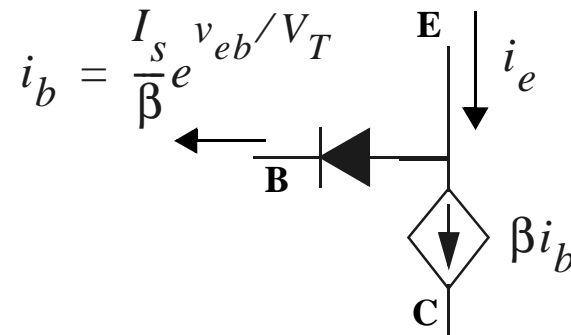


# PNP Equivalent Circuit Models

- We can model the PNP in the active region using diodes and controlled sources

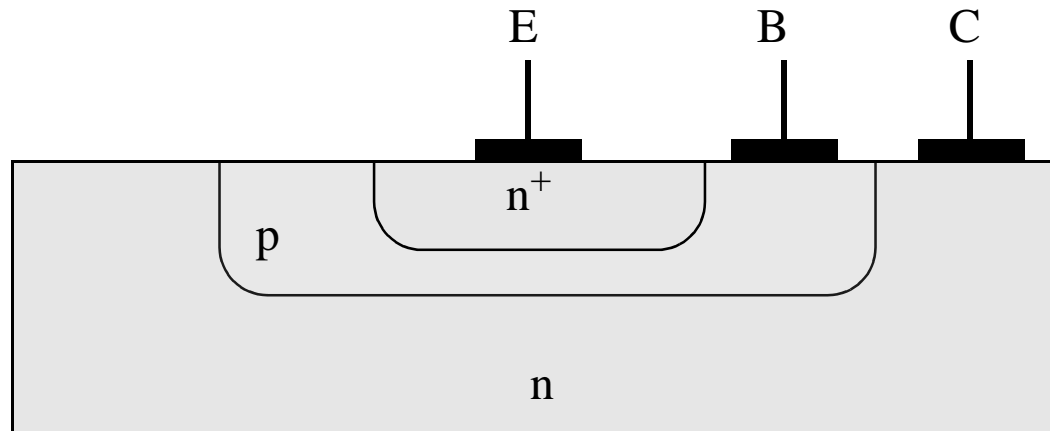


- The common emitter configuration is



## Collector and Emitter

- Note that while the emitter and collector are always of the same type, they are not interchangeable!
- They're doping levels are quite different



If you swap emitter and collector (EBJ reverse biased, CBJ forward) you get so-called inverse mode of operation. It is like active region, but the current transistor usually has much worse performance.